

熱化學氣相沉積奈米碳管之前處理與後處理技術

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摘要

為了研究奈米碳管表面結構對場發射特性之影響，我們使用氨基氣體對催化劑金屬前處理、電漿對奈米碳管後處理以及酸性化學溶液對奈米碳管做後處理等方法，目的是為了修飾奈米碳管的表面型態及改變炭奈米管的表面結構，進一步增強奈米碳管的場發射特性。研究的過程中，利用掃描式電子顯微鏡(scanning electron microscopy, SEM)及穿透式電子顯微鏡(transmission electron microscopy, TEM)觀察催化劑金屬顆粒的大小，及觀察碳管的表面形態及管壁結構，並使用拉曼頻譜(Raman spectroscopy)與能量散射光譜儀EDS(electron dispersive spectrometer, EDS)分析奈米碳管表面結構與組成成份的改變，從實驗數據清楚的顯示使用氨基氣體對催化劑金屬前處理、電漿對奈米碳管後處理以及酸性化學溶對奈米碳管做後處理等三種處理方法，可以有效的增強奈米碳管的場發射特性。場發射特性增強的主要原因為奈米碳管經前處理及後處理過後，碳管的表面結構產生改變，造成場發射點數目的增加及表面功函數的降低。

關鍵詞：奈米碳管、場發射

目錄

TABLE OF CONTENTS 封面內頁 簽名頁 AUTHORIZATION LETTER	iii
ABSTRACT	iv 中文摘要
iv 謹謝	vi
TABLE OF CONTENTS	vii LIST OF ILLUSTRATIONS
xi LIST OF TABLES	xix
Chapter 1 Introduction	1 1.1 Historical Introduction
1 1.2 Carbon Nanotube Structures	4 1.2.1
Single-Wall Carbon Nanotubes	5 1.2.2 Multi-Wall Carbon Nanotubes
8 1.3 Properties of Carbon Nanotubes	9 1.3.1 Electronic Properties
10 1.3.2 Optical Properties	13 1.3.4 Mechanical Properties
12 1.3.3 Magnetic Properties	14 1.4 Synthesis of Carbon Nanotubes
16 1.4.1 Arc-Discharge Technique	16 1.4.2 Laser Vaporisation Method
17 1.4.3 Chemical Vapour Deposition	19 1.5
Growth Mechanism of Carbon Nanotubes	22 1.5.1 Hydrocarbon Decomposition by Catalyst Nanoparticles
23 1.5.2 CNT Growth Modes	24 1.5.3 Surface Vs. Bulk Diffusion of Carbon and Effects on CNT Growth
24 1.6 Applications of Carbon Nanotubes	27 Chapter 2 Literature Review
26 1.7 Purpose of Investigation	31 2.1 Theory of Field Emission
.	31 2.1.1 Fowler-Nordheim Equation of Field Emission
.	32 2.1.2 Fowler-Nordheim Plot
.	34 2.2 Literature Review: Factors that Affect Field Emission from CNTs
2.2.1 Temperature of the CNT	36 2.2.2 Ambient Pressure of the Surrounding Gas During Field Emission
37 2.2.3 Type of Ambient Gas Environment	39 2.2.4 Type, Alignment, Inter-tube Spacing, cap-structure and Geometry of the CNTs
.	41 2.2.5 Type of Substrate Material Used for CNT Growth
.	46 2.2.6 Conditions During CNT Growth
47 2.2.7 Device Configuration	48
2.2.8 Source Used for CNT Synthesis	50 2.2.9 Surface Treatment – Gas Exposure
.	51 2.2.10 Doping
.	53 Chapter 3 Experimental procedure and Analytical Techniques
.	55 3.1 Fabrication Equipment
.	55 3.1.1 Thermal Evaporation System
.	55 3.1.2 CNT Synthesis – Thermal Chemical Vapor Deposition
.	57 3.2 Analytical Techniques
.	59 3.2.1 Scanning Electron Microscopy
.	59 3.2.2 Characteristic X-rays and

Energy Dispersive Spectroscopy (EDS)	67	3.2.3 Raman Spectroscopy	69
3.2.4 Experiment using TEM	78	3.2.5 Field Emission Measurement System	78
.	82	Chapter 4 Effects of Annealing Ni Catalyst in N ₂ O/N ₂ /NH ₃ on Surface Morphology and Field Emission Properties of Carbon Nanotubes	82
4.1 Introduction	86	4.2 Sample Preparation and characterization	88
4.3 Effects of Annealing Ni Catalyst in N ₂ O/N ₂ /NH ₃ on Surface Morphology of Carbon Nanotubes	91	4.3 Effects of Annealing Ni Catalyst in N ₂ O/N ₂ /NH ₃ on Surface Morphology of Carbon Nanotubes	91
The Effects of Annealing Ni Catalyst in N ₂ O/N ₂ /NH ₃ on Field Emission Properties of Carbon Nanotubes	101	4.4 Conclusions	104
104 Chapter 5 Plasma Treatment Effects on Surface Morphology and Field Emission Properties of Carbon Nanotubes	106	Chapter 5 Plasma Treatment Effects on Surface Morphology of Carbon Nanotubes	106
5.1 Introduction	107	5.2 Sample Preparation and Characterization	107
5.3 Plasma Treatment Effects on Surface Morphology of Carbon Nanotubes	108	5.3 Plasma Treatment Effects on Surface Morphology of Carbon Nanotubes	108
5.4 Plasma Treatment Effects on Field Emission Properties of Carbon Nanotubes	110	5.4 Plasma Treatment Effects on Field Emission Properties of Carbon Nanotubes	110
5.5 Conclusions	117	5.5 Conclusions	119
Chapter 6 Acidic Solutions Treatment Effects on Surface Morphology and Field Emission Characteristics of Carbon Nanotubes	119	Chapter 6 Acidic Solutions Treatment Effects on Surface Morphology and Field Emission Characteristics of Carbon Nanotubes	119
6.1 Introduction	120	6.2 Sample Preparation and Characterization	120
6.3 Acidic Solutions Treatment Effects on Surface Morphology of Carbon Nanotubes	122	6.3 Acidic Solutions Treatment Effects on Surface Morphology of Carbon Nanotubes	122
6.4 Acidic Solutions Treatment Effects on Field Emission Properties of Carbon Nanotubes	123	6.4 Acidic Solutions Treatment Effects on Field Emission Properties of Carbon Nanotubes	123
6.5 Conclusions	133	6.5 Conclusions	133
Chapter 7 Summary and Conclusion	136	Chapter 7 Summary and Conclusion	136
7.1 Summary and Results	137	7.2 Suggestions for Future Work	137
7.2 Suggestions for Future Work	139	Reference	139
	141		

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